

3/20 (WED)		
<b>Nanomaterials 6</b> Chair: Seiichi Hata (Nagoya University) Room C	<b>Plasma Science &amp; Technologies 4</b> <b>Surface and Thin Films</b> Chair: Makoto Kambara (The University of Tokyo) Room E	<b>Nitride Semiconductors 5</b> <b>Plasma and Surface Processing</b> Chair: Makoto Miyoshi (Nagoya Institute of Technology) Room F
<b>9:30-10:00</b> <20aC01I> <b>Invited Lecture</b> Koji Morita National Institute for Materials Science (NIMS) "Fabrication of High Strength Transparent Ceramics through Spark-plasma-sintering (SPS) Method"		<b>9:30-10:00</b> <20aF01I> <b>Invited Lecture</b> Yasuhide Sano Osaka University "Development of Array-type Plasma Generator for High-throughput Numerically Controlled Processes"
<b>10:00-10:30</b> <20aC02I> <b>Invited Lecture</b> Yoshiaki Nakamura Osaka University "Design of Semiconductor Nanoarchitecture for Thermoelectric Property Control"	<b>10:00-10:15 1216</b> <20aE02O> Hirotugu Sugiura "Control of sp <sup>2</sup> -C Fraction and Hardness of Amorphous Carbon Films by Formation of Precursor Radicals Depending on a Residence Time" <sup>1</sup> Hirotugu Sugiura, <sup>1</sup> Yasuyuki Ohashi, <sup>1</sup> Lingyun Jia, <sup>1</sup> Hiroki Kondo, <sup>1</sup> Kenji Ishikawa, <sup>1</sup> Takayoshi Tsutsumi, <sup>1</sup> Toshio Hayashi, <sup>2</sup> Keigo Takeda, <sup>1</sup> Makoto Sekine and <sup>1</sup> Masaru Hori <sup>1</sup> Nagoya University <sup>2</sup> Meijo University	<b>10:00-10:30</b> <20aF02I> <b>Invited Lecture</b> Hideo Aida "Challenges Toward Prospective Precise Polishing Techniques by Fusing Environmental Controlling and Plasma Technology" Nagaoka University of Technology
<b>10:30-10:45 1316</b> <20aC03O> Ryo Nagai "Impact of Boron Doping into Si Quantum Dots with Ge Core on Their Photoluminescence Properties" Ryo Nagai, Shuntaro Fujimori, Takuya Maehara, Katsunori Makihara, Akio Ohta, Mitsuhsisa Ikeda and Seiichi Miyazaki Nagoya University	<b>10:15-10:30 1160</b> <20aE03O> Masayuki Nakamura "Plasma diagnostics on TiN Film Deposition using High Power Impulse Magnetron Sputtering" Masayuki Nakamura, Keigo Takeda and Takayuki Ohta Meijo University	<b>10:30-10:45 1121</b> <20aF03O> Shun Suzuki "Resonant Raman Scattering Analyses of the Bi-axial Strain on the Surface of GaN and ZnO Generated by Mechanical Polish" Shun Suzuki, Shun Otake, Hiroyuki Iwata and Nobuhiko Sawaki Aichi Institute of Technology

<b>10:45-11:00 1155</b> <20aC04O> Chia-Yu NMI Liu "Piezotronics Effect on Photoelectrochemical Water Splitting of Porous ZnO Nanorod Arrays" Chia-Yu Liu and Chuan-Pu Liu Cheng Kung University	<b>10:45-11:00 1289</b> <20aE05O> Pavel Baroch "Advantages of Reactive HiPIMS for Preparation of Tunable Properties of IGZO Thin Films" Pavel Baroch, Jiri Rezek, Michal Prochazka and Jiri Houska University of West Bohemia	<b>10:45-11:00 1037</b> <20aF04O> Yue Xu "Study of GaN (0001) Surface Cleaning Using HCl-based Solutions" <sup>1</sup> Yue Xu, <sup>1</sup> Akio Ohta, <sup>1</sup> Mitsuhisa Ikeda, <sup>1</sup> Katsunori Makihara, <sup>2</sup> Noriyuki Taoka, <sup>3</sup> Tetsuo Narita, <sup>3</sup> Daigo Kikuta, <sup>1</sup> Koji Shiozaki, <sup>1</sup> Tetsu Kachi and <sup>1</sup> Seiichi Miyazaki <sup>1</sup> Nagoya University <sup>2</sup> AIST <sup>3</sup> Toyota Central R&D Labs., Inc.
<b>11:00-11:15 1282</b> <20aC05O> Yen-Sheng Lin "Enhanced Optoelectronic Properties of Al Doped ZnO Layers on Flexible Substrate by Optimizing the Distribution of CuO Nano-wire Structures" <sup>1</sup> Yen-Sheng Lin, <sup>1</sup> Jhe-Wei Lai, <sup>2</sup> Fadli Rohman and <sup>2</sup> Joachim Mayer <sup>1</sup> I-Shou University <sup>2</sup> RWTH Aachen University	<b>11:00-11:15 1021</b> <20aE06O> Yu Chao "Sputtering Synthesis of Dual Phase SnO <sub>2</sub> -WO <sub>3</sub> Nanocomposite Films and Their Gas-sensing Behaviors" Yu Chao and Y. C. Liang National Taiwan Ocean University	<b>11:00-11:15 1033</b> <20aF05O> Atsushi Tanide "The Effects of Hydrogen and Chroline Gas onto Sputtering Growth of GaN Films" <sup>1,3</sup> Atsushi Tanide, <sup>1</sup> Shohei Nakamura, <sup>1,3</sup> Akira Horikoshi, <sup>1</sup> Shigeru Takatsuji, <sup>1,3</sup> Motohiro Kohno, <sup>1</sup> Kazuo Kinose, <sup>1</sup> Soichi Nadahara, <sup>2</sup> Masazumi Nishikawa, <sup>2</sup> Akinori Ebe and <sup>3</sup> Kenji Ishikawa <sup>1</sup> Screen Holdings Co., Ltd. <sup>2</sup> EMD Corp. <sup>3</sup> Nagoya University
<b>11:15-11:30 1020</b> <20aC06O> Liu Yen-Chen "Sputtering Sythesis of ZnFe <sub>2</sub> O <sub>4</sub> -TiO <sub>2</sub> Nanorods and Their Photodegradation Ability Toward Organic Dyes" Y.C Liu and Y.C Liang National Taiwan Ocean University		<b>11:15-11:30 1054</b> <20aF06O> Yasuyuki Kobayashi "Plasma-assisted Molecular Beam Epitaxy Growth of GaN Thin Films on Sapphire Substrates Using h-BN/AlN Buffer Layers" <sup>1</sup> Yasuyuki Kobayashi, <sup>1</sup> Keiichi Nakata, <sup>1</sup> Hideki Nakazawa, <sup>1</sup> Hiroshi Okamoto, <sup>2</sup> Masanobu Hiroki and <sup>2</sup> Kazuhide Kumakura <sup>1</sup> Hirosaki University <sup>2</sup> NTT Basic Research Laboratories

**Plenary Lecture**

Chair: Masaru Hori (Nagoya University)  
Room B

**11:45-12:35**

&lt;20aB07P&gt;

**Plenary Lecture**

Maki Kawai

Institute for Molecular Science

"NOVEL FEATURE OF MOLECULES Induced by the Interaction with Substrate"

**Lunch Break 12:20-14:00**

**Topical Session 2****Recent Progress in Plasma Medicine**

Chair: Kenji Ishikawa (Nagoya University)  
Room B

**14:00-14:30****Invited Lecture**

<20aB08I>  
Jean-Michel Pouvesle  
CNRS/Université d'Orléans  
"Plasma/Target Interactions in Non-thermal Atmospheric Plasma Biomedical Applications: A Challenge and Key Issue"

**14:30-15:00****Invited Lecture**

<20aB09I>  
Endre Szili  
University of South Australia  
"On the Role of Plasma in Biofilm Formation"

**15:00-15:30****Invited Lecture**

<20aB10I>  
Eun Ha Choi  
Kwangwoon University  
"Nonthermal Biocompatible Plasma (NBP) Sources and their Applications to Plasma Medicine and Agricultures"

**15:30-16:00****Invited Lecture**

<20aB11I>  
Emilio Martines  
Consorzio RFX  
"Interaction of Cold Atmospheric Plasmas with Cell Membranes"

**Invited Lecture****Prof. Riccardo d'Agostino Memorial Session**

Chair: Mineo Hiramatsu (Meijo University)  
Room E

**Nitride Semiconductors 6****Optical Devices**

Chair: Tetsuya Takeuchi (Meijo University), Xuelen Wang (AIST)  
Room F

**16:15-16:45****Invited Lecture**

<20aE12I>  
Pietro Favia  
University of Bari  
"Remembering the Contribution of Prof. Riccardo d'Agostino to Plasma Science and Technology"

**16:15-16:45****Invited Lecture**

<20aF12I>  
Satoshi Kamiyama  
Meijo University  
"Potential of GaInN Multi-quantum-shell (MOS) in Nitride Optoelectronic Devices"

**16:45-17:15****Invited Lecture**

Ta-chin Wei  
Chung Yuan Christian University  
"T.B.A."

**17:15-17:45****Invited Lecture**

Jean-Michel Pouvesle  
CNRS/Université d'Orléans  
"Material Processing by Atmospheric Pressure Plasma Jets in Memory of Riccardo D'Agostino"

<sup>1</sup>Jean-Michel Pouvesle, <sup>1</sup>Azadeh Valinattajomran,  
<sup>2</sup>Céline Vivien, <sup>1</sup>Sébastien Dozias and <sup>1</sup>Éric Robert  
<sup>1</sup>GREMI CNRS / Université d'Orléans  
<sup>2</sup>IEMN CNRS / Université Lille

**17:15-17:30 1131****<20aF13O>**

Cheng-Jie Wang  
"InGaN-Based Resonant-Cavity Light-Emitting Diode with Embedded Porous-GaN and Top Dielectric Reflectors"  
Cheng-Jie Wang, Sheng-Min Wang, Ting-Wei Chung and Chia-Feng Lin  
National Chung Hsing University

**17:30-17:45 1199**  
<20aF14O>  
**Ryosuke Iida**  
"Embedded SiO<sub>2</sub> waveguide structures for GaInN VCSELs"  
<sup>1</sup>Ryosuke Iida, <sup>1</sup>Wataru Muranaga,  
<sup>1</sup>Syo Iwaya, <sup>1</sup>Tetsuya Takeuchi, <sup>1</sup>Satoshi Kamiyama,  
<sup>1</sup>Motoaki Iwaya and <sup>1,2</sup>Isamu Akasaki  
<sup>1</sup>Meijo University  
<sup>2</sup>Nagoya University

**17:45-18:15**  
<20aE15I>  
**Invited Lecture**  
Masaru Hori  
Nagoya University  
"A Door of Plasma Chemistry toward Bio Innovations  
Opened by Professor Riccard D'Agostino"

**18:15-18:45**  
<20aE16I>  
**Invited Lecture**  
Tatsuru Shirafuji  
Osaka City University  
"Functional Thin Film Formation Localized at Plasma/Liquid  
Interface: A New Perspective of Plasma Polymerization  
Dedicated to Prof. Riccardo d'Aqostino  
(June 17, 1942-April 21, 2018)"